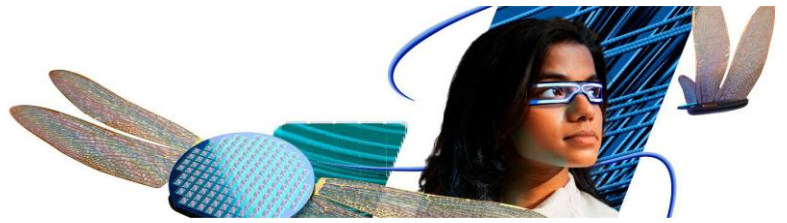


Global Innovation Index 2026

Powering entrepreneurs at the frontier of science

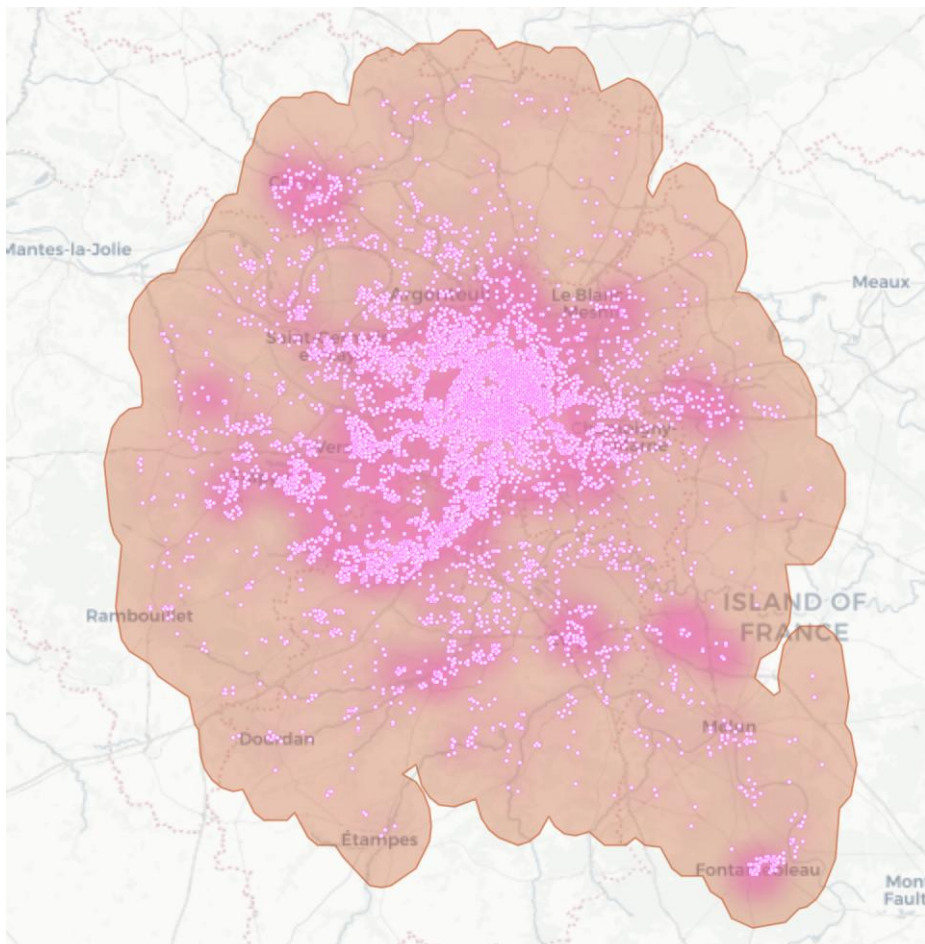


Paris, France

Paris is the top-ranked cluster, out of 2 French clusters, that falls within the top 100 innovation clusters in 2026. Over the most recent five-year period, the cluster accounted for, on a fractional basis, **16,654 PCT applications** and **60,375 scientific articles**, as well as **4,010 venture capital deals**, making it

11th in the World's Top 100 Innovation Cluster Rankings for 2026

(Also the 33rd innovation cluster by intensity)



Note: Points represent the location of an inventor, author, or VC deal. Map created with Leaflet. Map data © OpenStreetMap contributors, © CARTO
Source: WIPO Statistics Database, June 2026.

Global Innovation Index 2026

Powering entrepreneurs at the frontier of science



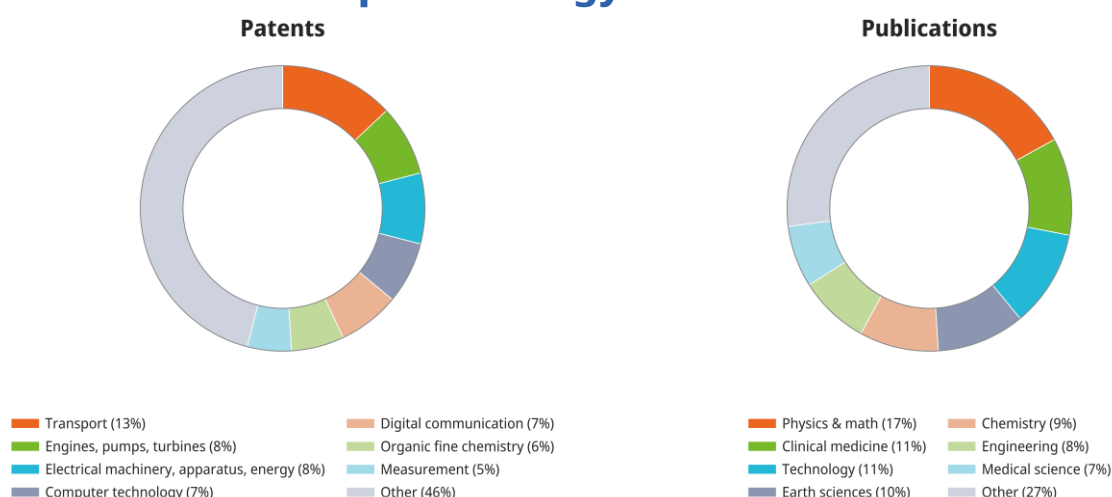
Top PCT applicants

		Patents ²	Share
1	SAFRAN AIRCRAFT ENGINES	959	6%
2	L'OREAL	895	5%
3	VALEO	608	4%

Top publishing organizations

		Articles ²	Share
1	UNIVERSITE PARIS-SACLAY	5,093	16%
2	SORBONNE UNIVERSITY	5,005	16%
3	UDICE	1,844	6%

Top technology fields in Paris



34% of Paris's PCT patent applications are filed in collaboration with other inventors located outside the cluster, with **Munich**, **Lyon** and **Helsinki** emerging as the top collaborative locations.

83% of Paris's scientific articles are published in collaboration with other organizations located outside the cluster, with the top three collaborating locations being **Lyon**, **London** and **Amsterdam-Rotterdam**.

Estimated cluster population		11,392,578			
Innovation Metric	Five-year total (#)			With multiple inventors/authors (#)	
	Unique count ¹	Fractional count ²	Per 1 million inhabitants	Total	External collaborator(s)
PCT applications	20,485	16,654	1,462	17,399	6,872
Scientific publications	142,675	60,375	5,300	138,942	118,123
Venture capital deals	4,010	n/a	352	n/a	n/a

¹ Distinct count of patents/articles involving local inventors/authors (non-additive). ² Sum of fractional shares based on local inventor/author counts, preventing double-counting.